## **IN THE CLAIMS:**

6. (Once amended) A microscope system for inspection during semiconductor

manufacture comprising:

a laser module;

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a microscope;

a coupling connecting the laser module to the microscope;

a pulsed laser for illumination, said laser being in the UV range; and

at least one rotating diffusion disk arranged behind the laser for the homogenization of the illumination.

- 7. (Once amended) The microscope system according to claim 6, including two diffusion disks rotating in opposite directions arranged directly or indirectly behind each other in an illumination ray path.
- 8. (Once amended) The microscope system according to claim 6, wherein the diffusion disk is either of a granulated or of a holographically produced design.
- 9. (Once amended) The microscope system according to claim 6, with a rotation speed of the diffuser disk of at least a magnitude that a rotation by at least one grain size or the resolution limit of a holographically generated structure or by the length of a structure takes place between two laser pulses.
- 10. (Once amended) The microscope system according to claim 6, with an illumination laser wavelength which essentially corresponds to an illumination wavelength during the manufacture of semiconductors.
- 11. (Once amended) The microscope system according to claim 10, wherein the illumination wavelength is in the range of 193nm or 248nm or 266nm or 366nm, all with a tolerance of

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## 12. Please cancel claim 12.

Contd Sul por 13. (Once Amended) In an inspection device for use in semiconductor manufacture, having a laser microscope, an improvement comprising:

a pulsed laser in the UV range;

and at least one rotating diffusion disk arranged behind the laser for the homogenization of the illumination.

## PLEASE ADD THE FOLLOWING NEW CLAIMS: S

- 14. (New) A microscope system for inspection during semiconductor manufacture comprising:
- a laser module;
- a microscope;
- a coupling connecting the laser module to the microscope;
- a pulsed laser for illumination, said laser being in the UV range;
- at least one continuously rotating diffusion disk arranged behind the laser for the homogenization of the illumination;

and wherein two diffusion disks rotate in opposite directions arranged directly or indirectly behind each other in an illumination ray path.

- 15. (New) A microscope system for inspection during semiconductor manufacture comprising:
- a laser module;
- a microscope;

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and a coupling connecting the laser module to the microscope;

a pulsed laser for illumination, said laser being in the UV range;

at least one continuously rotating diffusion disk arranged behind the laser for the

homogenization of the illumination;

wherein the diffusion disk is either of a granulated or of a holographically produced

design, and;

with a rotation speed of the diffuser disk of at least a magnitude that a rotation by at least one grain size or the resolution limit of a holographically generated structure or by the length of a structure takes place between two laser pulses.